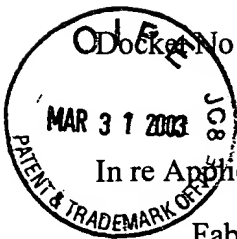


Docket No: 2013 USA P/DSM/PMD/JW

Patent

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Fabrice Geiger et al.

Application No.: 09/701,065

Filing Date: February 12, 2001

For: Methods For Forming Self-Planarized Dielectric Layer For Shallow Trench Isolation

Assistant Commissioner
for Patents
Washington, D.C. 20231

Examiner: Duda, Kathleen

Art Unit: 1756

Confirmation No.: 7160

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Respectfully submitted,
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